



UNIVERSITI PUTRA MALAYSIA

***STRUCTURAL, ELECTRICAL, OPTICAL AND THERMAL
PROPERTIES OF NICKEL SELENIDE***

CHIN PIK YEE

FS 2015 7



**STRUCTURAL, ELECTRICAL, OPTICAL AND THERMAL
PROPERTIES OF NICKEL SELENIDE**

By

CHIN PIK YEE

**Thesis Submitted to the School of Graduate Studies, Universiti Putra
Malaysia, in Fulfillment of the Requirements for the Degree of Master of
Science**

September 2015

All material contained within the thesis, including without limitation text, logos, icons, photographs and all other artwork, is copyright material of Universiti Putra Malaysia unless otherwise stated. Use may be made of any material contained within the thesis for non-commercial purposes from the copyright holder. Commercial use of material may only be made with the express, prior, written permission of Universiti Putra Malaysia.

Copyright © Universiti Putra Malaysia



DEDICATION

To my beloved parents
for their love and concern

To my supervisor Prof Dr. Zainal Abidin Talib
for his guidance, advice, understanding and endless support

To Dr. Josephine Liew Ying Chyi
for her guidance, advice and fully support

To my friends
for their wonderful encouragement and support

© COPYRIGHT UPM



Abstract of thesis presented to the Senate of Universiti Putra Malaysia in fulfillment of the requirement for the degree of Master of Science

STRUCTURAL, ELECTRICAL, OPTICAL AND THERMAL PROPERTIES OF NICKEL SELENIDE

By

CHIN PIK YEE

September 2015

Chairman : Professor Zainal Abidin Talib, PhD
Faculty: Science

Fundamental studies are very crucial to generate new knowledge. In this respect, bulk material is useful to understand the characteristic of the material. Nickel selenide (NiSe) has been chosen because of its impressive photovoltaic properties and a wide range of industrial applications. To improve the solar conversion to electric efficiency, NiSe synthesized via solid state reaction method was annealed in the temperature range of 423 to 823 K.

The NiSe was in 1:1 stoichiometric form with single phase hexagonal crystal structure. FESEM micrographs showed the NiSe particle was in nanometer size. As the annealing temperature increased, the crystalline size increased from 52.7 nm to 142.8 nm while the dislocation density decreased from 36.01×10^{13} lines/m² to 4.90×10^{13} lines/m². The NiSe was a p-type semiconductor. As the NiSe annealed temperature increased, the electrical resistivity decreased from 0.0037 Ωcm to 0.00015 Ωcm. In addition, the Hall mobility increased from 1.21 cm²/Vs to 15.06 cm²/Vs. However, the sheet Hall coefficient and the sheet carrier density of the sample remained constant at 0.017 cm²/C and 3.19×10^{20} cm⁻² respectively. This indicates that at higher anneal temperatures, crystallite size will increase causing the electrical resistivity to decrease.

Optical analysis showed that the annealed NiSe has direct transition band gap energy in the range of 2.13 – 2.47 eV which is consistent with literature values. The decreased in the band gap of the sample with increasing annealing temperature can be interpreted as the increased in the crystallinity of the synthesized material. Photoacoustics analysis showed that as the annealed temperature increased, the surface recombination velocity decreased from 428.39 cm/s to 389.62 cm/s, while the thermal diffusivity, the diffusion coefficient and the band to band recombination lifetime of the NiSe increased from the 13.42×10^{-2} cm²/s to 20.81×10^{-2} cm²/s, from 4.56 cm²/s to 5.10 cm²/s, from 1.86 μs to 2.46 μs, respectively. This indicates that the diffused excess carrier through the NiSe surface has increased. The increasing of the surface recombination process is due to the increasing of homogeneity and crystallinity of the samples.

In conclusion, increasing annealing temperature on NiSe has increased the crystallite size and decreased the dislocation density. The electrical resistivity and optical band gap also decreased, while the Hall mobility and thermal diffusivity increased. This work has shown that optimizing the annealing temperature is an important process to improve the quality of the bulk NiSe.



Abstrak tesis yang dikemukakan kepada Senat Universiti Putra Malaysia
sebagai memenuhi keperluan untuk ijazah Sarjana Sains

SIFAT-SIFAT STRUKTUR, ELEKTRIK, OPTIK DAN TERMA UNTUK NIKEL SELENIDE

By

CHIN PIK YEE

September 2015

Pengerusi: Professor Zainal Abidin Talib, PhD
Fakulti: Sains

Kajian asas adalah sangat penting untuk menghasilkan ilmu pengetahuan baru. Dalam hal ini, bahan pukal adalah berguna untuk memahami sifat-sifat bahan. Nikel Selenida (NiSe) telah dipilih kerana sifat fotovoltannya yang mengagumkan dan mempunyai aplikasi industri yang luas. Untuk meningkatkan penukaran solar kepada elektrik berkesan, NiSe disintesis melalui kaedah tindak balas keadaan pepejal telah disepuhli dalam suhu 423 hingga 823 K.

NiSe adalah dalam keadaan stoikiometri 1:1, fasa tunggal yang berstruktur kristal heksagon. Mikrograf FESEM menunjukkan zarah NiSe adalah dalam saiz nanometer. Apabila suhu penyepuhli meningkat, saiz kristalit meningkat dari 52.7 nm hingga 142.8 nm, manakala ketumpatan kehelan menurun dari 36.01×10^{13} garis/m² hingga 4.90×10^{13} garis/m². NiSe adalah semikonduktor jenis p. Apabila suhu penyepuhli meningkat, kerintangan elektrik bagi sampel telah berkurang dari 0.0037 Ω cm hingga 0.00015 Ω cm. Tambahan pula, kebolehergerakan Hall meningkat dari 1.21 cm²/Vs hingga 15.06 cm²/Vs. Walau bagaimanapun pemalar Hall dan ketumpatan pengangkutan adalah tetap masing-masing pada 0.017 cm²/C dan 3.19×10^{20} cm⁻². Ini menunjukkan pada suhu penyepuhli yang tinggi, saiz kristal akan meningkat menyebabkan kerintangan elektrik berkurang.

Analisis optik menunjukkan NiSe yang telah disepuhli mempunyai tenaga jurang jalur peralihan terus dalam julat 2.13 – 2.47 eV dimana bersetuju dengan nilai kesusasteraan. Tenaga jurang jalur bagi sampel berkurang apabila suhu penyepuhli meningkat boleh ditafsir sebagai peningkatan penghabluran. Apabila suhu penyepuhli meningkat, analisis fotoakustik menunjukkan halaju penggabungan semula permukaan berkurang dari 428.39 cm/s hingga 389.62 cm/s, manakala peresapan haba, pemalar resapan dan masa penggabungan semula jalur ke jalur masing-masing meningkat dari 13.42×10^{-2} cm²/s hingga 20.81×10^{-2} cm²/s, dari 4.56 cm²/s hingga 5.10 cm²/s, dari 1.86 μ s hingga 2.46 μ s. Ini menunjukkan lebih pembawa yang meresap melalui permukaan NiSe telah bertambah. Proses penggabungan semula permukaan meningkat disebabkan oleh kehomogenan dan penghabluran sampel meningkat.

Kesimpulannya, peningkatan suhu penyepuhlindapan bagi NiSe telah meningkatkan saiz kristalit, dan mengurangkan ketumpatan kehelan. Kerintangan elektrik dan jurang jalur optik juga berkurang, manakala keboleherakan Hall dan peresapan haba meningkat. Kajian ini telah menunjukkan suhu penyepuhlindapan yang optimum adalah proses yang penting untuk meningkatkan kualiti NiSe.



ACKNOWLEDGEMENTS

First of all, I would like to express my sincere appreciation and gratitude to my supervisor, Professor Dr. Zainal Abidin Talib and co-supervisor Professor Dr. Wan Mahmood Mat Yunus for their invaluable advice, guidance and assistance throughout the duration of this project.

Special appreciation are also given to Dr. Josephine Liew Ying Chyi, Dr. Nordin Bin Hj Sabli, Dr. Kasra, Dr. Abdullah, Dr. Zaidan, Dr. Lim, Dr. Yap, Dr. Khor, Dr. Chen, Dr. Emma for their advice and helpful during this period of study. I would also like to thank to all the staff in Chemistry and Physics department especially Pn. Rohani Bt Ahdirin, Pn. Kamsiah Alias, Pn. Norhaslinda Noruddin, Pn. Nik Afida Anis Azahani, Pn. Aini, Mr. Abbas and Mr. Roslim for their help and co-operation given to me throughout my work.

Special thanks to Pn. Aminah Jusoh and Mr. Rafiuz Zaman Haroun (Institute of Bioscience, UPM) for helping me in handling FESEM and EDX. I also would like to extend special thanks to all my friends in laboratory 201 for their assistance and guidance in operating the instruments which are essential in this study.

I am gratefully acknowledge to the Ministry of Education, Universiti Putra Malaysia for providing the Grant No Vot ERGS: 5527051 for their financial support which enable me to undertake this work. Last but not least, my sincere thanks to all my family members, teachers, seniors and friends, who involved directly or indirectly towards the success of this project.

I certify that an Examination Committee has met on 05.09.2015 to conduct the final examination of Chin Pik Yee on her degree of Master of Science thesis entitled “Structural, Electrical, Optical, and Thermal Properties of Nickel Selenide” in accordance with Universities and University Colleges Act 1971 and the Constitution of the Universiti Putra Malaysia [P.U.(A) 106] 15 March 1998. The committee recommends that the student be awarded the Master of Science.

Members of the Thesis Examination Committee were as follows:

Khamirul Amin b. Matori, PhD
Associate Professor
Faculty of Science
Universiti Putra Malaysia
(Chairman)

Zaidan b. Abdul Wahab, PhD
Associate Professor
Faculty of Science
Universiti Putra Malaysia
(Internal Examiner)

Chen Soo Kien, PhD
Associate Professor
Faculty of Science
Universiti Putra Malaysia
(Internal Examiner)

Mohammad Hafizuddin Haji Jumali, PhD
Lecturer
Faculty of Science and Technology
Universiti Kebangsaan Malaysia
(External Examiner)

ZUKARNAIN ZAINAL, PhD
Professor and Deputy Dean
School of Graduates Studies
Universiti Putra Malaysia

Date:

This thesis was submitted to the Senate of Universiti Putra Malaysia and has been accepted as fulfillment of the requirement for the degree of Master of Science. The members of the Supervisory Committee were as follows:

Zainal Abidin Talib, PhD

Professor
Faculty of Science
Universiti Putra Malaysia
(Chairman)

W. Mahmood Mat Yunus, PhD

Professor
Faculty of Science
Universiti Putra Malaysia
(Member)

BUJANG KIM HUAT, PhD

Professor and Dean
School of Graduates Studies
Universiti Putra Malaysia

Date:

Declaration by graduate student

I hereby confirm that:

- this thesis is my original work;
- quotations, illustrations and citations have been duly referenced;
- this thesis has not been submitted previously or concurrently for any other degree at any other institutions;
- intellectual property from the thesis and copyright of thesis are fully-owned by Universiti Putra Malaysia, as according to the Universiti Putra Malaysia (Research) Rules 2012;
- written permission must be obtained from supervisor and the office of Deputy Vice-Chancellor (Research and Innovation) before thesis is published (in the form of written, printed or in electronic form) including books, journals, modules, proceedings, popular writings, seminar papers, manuscripts, posters, reports, lecture notes, learning modules or any other materials as stated in the Universiti Putra Malaysia (Research) Rules 2012;
- there is no plagiarism or data falsification/fabrication in the thesis, and scholarly integrity is upheld as according to the Universiti Putra Malaysia (Graduate Studies) Rules 2003 (Revision 2012-2013) and the Universiti Putra Malaysia (Research) Rules 2012. The thesis has undergone plagiarism detection software.

Signature: _____ Date: 12 November 2015

Name and Matric No.: Chin Pik Yee (GS31992)

Declaration by Members of Supervisory Committee

This is to confirm that:

- the research conducted and the writing of this thesis was under our supervision;
- supervision responsibilities as stated in the Universiti Putra Malaysia (Graduate Studies) Rules 2003 (Revision 2012-2013) are adhered to.

Signature: _____

Name of Chairman of Supervisory Committee:

Zainal Abidin Talib, PhD

Signature: _____

Name of Member of Supervisory Committee:

W. Mahmood Mat Yunus, PhD

TABLE OF CONTENTS

	Page
ABSTRACT	i
ABSTRAK	iii
ACKNOWLEDGEMENTS	v
APPROVAL	vi
DECLARATION	viii
LIST OF TABLES	xii
LIST OF FIGURES	xiii
LIST OF ABBREVIATIONS	xvi
CHAPTER	
1 INTRODUCTION	1
1.1 Introduction	1
1.2 Nickel Selenide	2
1.3 Photoacoustic technique	3
1.4 Problem statement	3
1.5 Research aim	4
1.6 Research Objectives	4
1.7 Scope of the study	4
2 LITERATURE REVIEW	5
2.1 Synthesis of Nickel Selenide	5
2.2 Optical Studies	11
2.3 Thermal Properties	13
2.4 Electrical properties	14
2.5 Photoacoustics Characterization of Semiconductor	15
3 MATERIALS AND METHODS	16
3.1 Sample Preparation	16
3.1.1 Solid State Reaction Technique for Powder Fabrication	16
3.1.2 Pelletizing Synthesized Powder	17
3.1.3 Annealing Process	18
3.2 Sample Characterization	18
3.2.1 X-Ray Diffraction Analysis (XRD)	18
3.2.2 Field Emission Scanning Electron Microscopy (FESEM)	19
3.2.3 Energy Dispersion X-Ray Florescence Spectroscopy (ED-XRF)	20
3.2.4 Energy Dispersive X-ray (EDX) Analysis	20
3.2.5 Van der Pauw Technique	20
3.2.6 Thermogravimetric Analysis (TGA)	23

3.2.7	Laser Flash Measurement	23
3.2.8	UV- Vis-Nir Spectroscopy	24
3.2.9	Open Photoacoustics Technique	25
	3.2.9.1 Open Photoacoustics Cell (OPC)	26
	3.2.9.2 Signal Processing	26
	3.2.9.3 Thermal and Carrier Transport Properties Measurement using OPC Technique	28
	3.2.9.4 Data Analysis	28
4	RESULTS AND DISCUSSION	30
4.1	Introduction	30
4.2	Synthesis and Characterization of Nickel Selenide	30
4.2.1	Structural Analysis	30
4.2.2	Compositional and Morphological Analysis	35
4.2.3	Thermal Analysis	39
4.2.4	Electrical Analysis	41
4.2.5	Optical Analysis	50
4.2.6	Photoacoustics Analysis	52
	4.2.6.1 Effect of NiSe Thickness on Phase Signal	52
	4.2.6.2 Annealing Effect On Carrier Transport Properties of Sample NiSe	61
5	CONCLUSION	68
5.1	Conclusion	68
5.2	Recommendation	69
	REFERENCES	70
	BIODATA OF STUDENT	76
	LIST OF CONFERENCES ATTENDED/ PUBLICATION	77

LIST OF TABLES

Table		Page
4.1	Comparison between the JCPDS data (Ref. 98-009-0268) and experimentally observed values for NiSe powders prepared by solid-state reaction method.	51
4.2	Elemental composition analysis using EDX technique of as synthesized NiSe powder and after annealing at difference temperatures.	58
4.3	Elemental composition analysis using XRF technique of as synthesized NiSe powder and after annealing at different temperatures.	59
4.4	The average particle size of as synthesized and annealed NiSe powder.	59

LIST OF FIGURES

Figure		Page
3.1	Quartz ampoule used for NiSe solid state reaction.	16
3.2	Temperature profile of NiSe heat treatment.	17
3.3	Pellet mould (10 mm in diameter).	18
3.4	Symmetrical circular geometry with silver paint contacts placed at the boundary for Van der Pauw resistivity measurement.	20
3.5	Schematic diagram system Van der Pauw measurement method.	21
3.6	Van Der Pauw technique for resistivity measurement.	22
3.7	Netzsch LFA 457 Microflash™ Laser Flash measurement (NETZSCH, 2006).	24
3.8	Experimental setup for open photoacoustic cell detection technique.	26
3.9	Cross section of the open photoacoustic cell.	27
4.1	XRD pattern of prepared NiSe powder by solid state reaction technique.	31
4.2	XRD pattern of NiSe powder annealed at different temperatures.	32
4.3	The Full Width at Half Maximum (FWHM) of the (011) peak of the XRD as a function of the annealing temperature of the NiSe sample.	33
4.4	The estimated mean crystallite size, L_g as a function of the annealing temperature of the NiSe sample.	34
4.5	The estimated dislocation density, D_δ as a function of the annealing temperature of the NiSe sample.	34
4.6	The estimated lattice strain of the synthesized NiSe powder as a function of the annealing temperature of the NiSe sample.	35
4.7	EDX spectrum for as prepared NiSe powder and after annealing at different temperatures.	36
4.8	FESEM images for (a) as synthesized and annealed	38

NiSe powder with temperature (b) 423 K, (c) 523 K, (d) 623 K, (e) 723 K, (f) 823 K.

4.9	TGA and DTG curve for synthesizing NiSe powder at heating rate 10 K/min.	39
4.10	Thermal diffusivity measurement versus sample thickness on NiSe pellet.	40
4.11	Thermal diffusivity versus annealing temperature for NiSe pellet.	41
4.12	Electrical resistivity as a function of temperature for (a) as-prepared NiSe and NiSe annealed at 423 K, 523 K; (b) NiSe annealed at 623 K, 723 K and 823 K.	42
4.13	Electrical resistivity of as prepared NiSe as a function of temperature.	43
4.14	Electrical resistivity of NiSe annealed temperature at 423 K as a function of temperature.	44
4.15	Electrical resistivity of NiSe annealed temperature at 523 K as a function of temperature.	44
4.16	Electrical resistivity of NiSe annealed temperature at 623 K as a function of temperature.	45
4.17	Electrical resistivity of NiSe annealed temperature at 723 K as a function of temperature.	45
4.18	Electrical resistivity of NiSe annealed temperature at 823 K as a function of temperature.	46
4.19	Electrical resistivity of NiSe at temperature 300K as a function of annealed temperature.	46
4.20	Room temperature at 6 000 G Hall mobility of NiSe as a function of annealed temperature.	48
4.21	Room temperature at 6 000 G of sheet Hall coefficient for NiSe as a function of annealed temperature.	49
4.22	Room temperature at 6 000 G of sheet carrier density for NiSe as a function of annealed temperature.	49
4.23	Variation of $(F(R)hv)^2$ versus hv for NiSe annealed at different temperature.	51
4.24	Direct band gap as a function of different annealing temperature of NiSe.	52

4.25	Phase signal versus chopping frequency for NiSe at different thickness.	53
4.26	Phase signal as a function of frequency for NiSe at (a) $l_s = 0.0390$ cm, (b) $l_s = 0.0539$ cm, (c) $l_s = 0.0638$ cm, (d) $l_s = 0.0780$ cm and (e) $l_s = 0.0839$ cm.	54-56
4.27	$\ln(\text{PA Signal})$ as a function of $\ln(\text{frequency})$ for sample NiSe with thickness 0.0638 cm.	57
4.28	Characteristic frequency as a function of sample thickness.	58
4.29	Thermal diffusivity as a function of sample thickness.	59
4.30	Diffusion coefficient as a function of sample thickness.	59
4.31	Surface recombination velocity as a function of sample thickness.	60
4.32	Band to band recombination lifetime as a function of NiSe sample thickness.	61
4.33	The PA Phase signal as a function of modulation frequency for different annealing temperature of the NiSe.	62
4.34	Phase signal as a function of modulation frequency of NiSe and best fit line for (a) as prepared NiSe sample and annealing sample at (b) 423 K and (c) 823 K.	62-63
4.35	Characteristic frequency as a function of annealing temperature of NiSe.	64
4.36	Thermal diffusivity as a function of annealing temperature of NiSe.	65
4.37	Diffusion coefficient as a function of annealing temperature of NiSe.	65
4.38	Surface recombination velocity as a function of annealing temperature of the NiSe sample.	66
4.39	Surface band to band recombination lifetime as a function of annealing temperature of the NiSe sample.	67

LIST OF ABBREVIATIONS

α_s	thermal diffusivity
α	absorption coefficient
A	proportional constant
B	magnetic field
β	full-width half maximum (FWHM)
ϕ	phase angle
D	carrier diffusion coefficient
D_δ	dislocation density
E	energy
E_g	band gap energy
F	Kubelka-Munk function
f	modulation frequency
f_c	characteristic frequency
h	Planck's constant
$h\nu$	energy of photons
I	current
l_s	thickness of the sample
L_g	mean crystallite size
l_β	optical length
λ	wavelength
μ_H	Hall mobility
n	index
N	carrier density
n	natural of the transition

Q	voltage ratios
q	electronic charge
R_{∞}	diffuse reflectance of the sample
R_H	Hall coefficient
ρ	resistivity
S	scattering coefficient
τ	surface band to band recombination lifetime
τ_{eff}	effective recombination lifetime
V	voltages
v	surface recombination velocity
μ_s	thermal diffusion length
θ_0	initial phase angle
θ	Bragg's angle
ω	light chopping angular frequency

© COPYRIGHT UPM



CHAPTER 1

INTRODUCTION

1.1 Introduction

Non-renewable energy fuel has been used for more than 150 years, and the explosion growth of the world population has ever increased our demand on the production of non-renewable energy fuel such as fossil fuel. However, our dependence on the fossil fuel will lead to global energy crisis wherein the decrease of the fuel reservoir will reduce fuel production. The decreasing of fuel production will lead to rising fuel price. This limitation of non-renewable energy and reducing production of non-renewable energy have been the motivation that have driven scientists to explore various approaches for clean, cheap and renewable energy.

The usage of fossil fuel causes the emission of greenhouse gases such as carbon dioxide, methane and nitrous oxide. This will lead to air pollution, water contamination, acid rain and global warming wherein our nature environment will be devastated, and humankind suffer various health problems due to the devastation of the environment. The utilization of nuclear energy can produce tons of energy, but it brings considerations such as proper waste management and safety issues. Thus, clean, cheap, environmentally friendly, sustainable and renewable energy resources are in serious demand. Renewable energy resources such as biomass, hydroelectric, wind, solar, hydrogen fuel, geothermal, ocean and wave are potential candidates that are growing rapidly in terms of research and small scale application.

Solar energy meets the world's energy demand wherein it does not contribute to the greenhouse gases in its energy production. Solar energy is produced directly from sunlight using photovoltaic devices. Photovoltaic device such as a semiconductor device transform photon energy from sunlight into electrical energy by utilizing photoelectric effect in a semiconductor. Photovoltaic device can be easily installed on the roof or the walls of a building. The fabrication process of a photovoltaic device can be different with various materials. Photovoltaic device's performance, cost of manufacturing, toxicity, and durability depend on the materials used and method of fabrication.

Metal chalcogenides semiconductors are formed by compounding sulfur, selenium or/and tellurium with other metal materials such as nickel and copper. Chalcogenides can form binary, ternary and quaternary compounds with other transition metal elements. Selenium based chalcogenides have excellent properties on photon absorption, electrical conduction, and it is relatively easier to control its crystallinity and a low band gap (Zhang et al. 1999, Hankere et al. 2010).

The band gap energy and the production cost are two important factors that need to be considered in producing photovoltaic device. The band gap energy must match with the solar spectrum in order for maximum absorption of solar photons (Zainal et al. 2005). This has resulted in semiconductors from Group VI-VIII to the forefront in consideration for fabrication of polycrystalline chalcogenides semiconductor. Nickel is less toxic and environmental friendly compared to lead and cadmium-based semiconductor (Shi et al. 2013). Nickel is also a cheaper material to fabricate polycrystalline chalcogenide semiconductor.

1.2 Nickel Selenide

Nickel selenide (NiSe) is a binary semiconductor compound which has received extensive attention because it exhibits desirable electronic and magnetic properties for solar energy production (Zhuang et al. 2006). NiSe is a p-type binary metal chalcogenide semiconductor with optical band gap of 620 nm (2.0 eV). Resistivity of NiSe thin film is $10^2 \Omega \text{cm}$ at room temperature. (Mane et al. 2000, Anuar et al. 2004, Zainal et al. 2005, Zhuang et al. 2006, Moloto et al. 2009, 2011, Sobhani et al. 2011, 2012). It has a wide range of potential applications in the field of material science fabrication of photovoltaic, electronic and optoelectronic devices such as optical recording material, solar cell, sensor, laser materials, optical fibers, superionic conductor, photodetectors, window material, thermoelectric converter, optical filter, electro-optical devices, and storage energy material (Xue et al. 2006, Moloto et al. 2009).

This research focused on NiSe compound, which has shown impressive photovoltaic properties and a wide range of industrial applications. Fundamental studies are paramount to generate new knowledge of the underlying foundations of phenomena and understanding that may prove crucial in applied research. Therefore, the relationship between synthesis method and the material's structural and physical properties will contribute in the development of greater fundamental science and engineering basis for the material. The fundamental investigation such as structural and physical properties (electrical, thermal, optical and transport properties) of nickel selenide compound will be carried out in this research. The research findings will help to further advancement of knowledge in basic material physics, which is important for technological application such as device substrate characterization and processing control.

In fundamental material physics studies, bulk material is useful to understand the characteristic of the material. Thus, the first objective of the present study was to synthesize the nickel selenide compound by using solid state reaction. This will be followed by characterizing the structural, optical, electrical, thermal, and transport properties of the materials via XRD, FESEM, EDX, ED-XRF, UV-Vis-NIR, Van Der Pauw technique, TGA, laser flash, and photoacoustic technique respectively. The bulk samples were heated under nitrogen gas to study the annealing effect on structural, thermal, optical, electrical and transport properties. The performance characteristic can lead us to understand the material properties. Consequently, these findings will provide the

fundamental knowledge that will help to improve the efficiency, design structure and decrease the manufacturing cost for photovoltaic solar cells devices.

From the survey of published work on the material under study, there is no detailed investigation especially on heat diffusion and carrier transport properties in nickel selenide bulk samples. Thus, the current work was carried out to study thermal and carrier transport properties of the nickel selenide bulk samples by using photoacoustic technique. The thermal and transport properties of nickel selenide bulk sample would provide useful information in future fabrication process of selenide based photovoltaic devices.

1.3 Photoacoustic Technique

Photothermal science is a study on phenomena based on the conversion of absorbed optical energy into heat. Alexander Graham Bell had carried out an experiment on a condensed matter sample (Favier, 1997) and found that when light beam periodically shines on the surface in an enclosed cell, it will produce a loud signal. This phenomenon known as photoacoustic which is an indirect acoustic signal produced by photothermal heating effect.

Rosencwaig and Gersho (1976) developed a thermal piston model where the pressure in the photoacoustic cell depends on the heat generated by the absorbed light. From the phenomena, a theory on the photoacoustic effect was derived which is known as R-G theory. This theory is the basis for other theories using microphone as photoacoustic detection on a solid sample. Since 1970's, the R-G theory has been widely used in subsequent photoacoustic study. The intense light sources, sensitive detection equipment and sensitive signal processing equipment are the three major factors in developing the photoacoustic research. The sensitivity of photoacoustic spectroscopy can be increased by using lasers or high-pressure arc lamps, sensitive detector such as a condenser and electrets microphones, and processed by filters and sensitive lock-in amplifiers. Photoacoustic spectroscopy is a very fast, sensitive and accurate tool for measuring the optical, thermal and carrier transport properties of solid samples. In this research, photoacoustic technique is used to characterize the optical, thermal and carrier transport properties of nickel selenide.

1.4 Problem Statement

Metal chalcogenide has excellent properties on photon absorption, electrical conduction, and have low band gap (Zhang et al. 1999, Hankere et al. 2010). To optimize photons absorption, the band gap energy must match with the solar spectrum (Zainal et al. 2005). Fundamental investigation on the structural and physical properties (electrical, thermal, optical and transport properties) is crucial to understand these properties. In addition, studying the annealing effect on the material will provide the fundamental knowledge that helps to improve the solar conversion to electric. Work from earlier researchers show that there is a need to further investigate on areas such as heat diffusion and carrier transport especially in nickel selenide bulk samples. Thus, the current

work was carried out to probe the annealing effect on the thermal and carrier transport properties of the nickel selenide bulk samples by using photoacoustic technique. The thermal and carrier transport properties of nickel selenide bulk sample would provide useful information in future fabrication process of selenide based photovoltaic devices.

1.5 Research aim

The research aim is to investigate the effect of annealing on transport properties of NiSe.

1.6 Research objectives

The objectives of the present work are as follow:

1. To synthesize the polycrystalline nickel selenide powder by using solid state reaction method.
2. To characterize and to study the annealing effect on the structural, composition, morphology, electrical, optical and thermal properties of the NiSe polycrystalline metal chalcogenides compound.

1.7 Scope of the study

This thesis is organized into five chapters. Chapter 1 is a brief introduction on motivation of the study which included the problem statement, aim and objectives of the research.

Chapter 2 is a survey of previous works on preparation method of nickel selenide. This chapter also discusses on previous research on the characteristics of the nickel selenide, and photoacoustic characterization of semiconductor.

Experimental details on the method of preparation of nickel selenide are discussed in Chapter 3. This includes the experimental setups and characterization techniques of XRD, ED-XRF, EDX, FESEM, TGA, laser flash, Van der Pauw, UV-Vis-NIR and photoacoustics spectroscopy.

All the experimental results on the structural, composition, morphology, electrical, thermal, optical and transport properties of nickel selenide are reported and discussed in detail in Chapter 4. The annealing effect on the structural, composition, morphology, electrical, thermal and optical properties of NiSe are also elaborated in detail in this chapter.

Finally, Chapter 5 summarizes all the present analysis work and provides conclusions on what valuable information has been learned beyond previously published work. Recommendations are also given for future research directions and experiments needed in this research area.

REFERENCES

- Almond, D.P., and Patel, P.M. *Photothermal Science and Techniques*; Academic Press: UK. 1996.
- Anand, T.J.S., Zaidana, and M., Shariza, S., *Procedia Engineering*, 2013. **53**: 555-561.
- Anuar, K., Zainal, Z., Saravanan, N., and Kartini, A.R., *Asean Journal Science and Technology Development*, 2004. **21**: 19-25.
- Athanassopoulou, M.D., Mergos, J.A., Palaiologopoulou, M.D., Argyropoulos, T.G., and Dervos, C.T., *Thin Solid Films*, 2012. **520**: 6515-6520.
- Baranov, A.I., Isaeva, A.A., Kloo, L., Kulbachinskii, V.A., Lunin, R.A., Nikiforov, V.N., and Popovkind, B.A., *Journal of Solid State Chemistry*, 2004. **177**: 3616-3625.
- Barbu, A., Cristea, Gh., Bratu, I., Mushinskii, V.P., and Bobis, I., *Journal of Molecular Structure*, 1997. **410-411**: 259-262.
- Berman, R. *Thermal conduction in solids*; Clarendon Press: Oxford. 1976.
- Bodeux, R., Leguay, J., and Delbos, S., *Thin Solid Films*, 2015. **582**: 229-232.
- Bouhdada A., Marrakh R., Vigue F., and Faurie J.P., *Microelectronics Reliability*, 2004. **44**: 223-228.
- Brennan, J.G., Siegrist, T., Kwon, Y.U., Stuczynski, S. M., and Steigerwald, M. L., *Journal of the American Chemical Society*, 1992. **114**: 10334-10338.
- Bushroa, A.R., Rahbari, R.G., Masjuki, H.H., and Muhamad, M.R., *Vacuum*, 2012. **86**: 1107-1112.
- Campos, C.E.M., Lima, J.C.D., Grandi, T.A., Itie, J.P., and Polian, A., *Solid State Ionic*, 2005(a). **176**: 2639-2644.
- Campos, C.E.M., Lima, J.C.D., Grandi, T.A., Machado, K.D., Itie, J.P., and Polian, A., *Journal of Solid State Chemistry*, 2005(b). **178**: 93-99.
- Campos, C.E.M., Lima, J.C.D., Grandi, T.A., Machado, K.D., Pizani, P.S., and Hinrichs, R., *Solid State Communications*, 2003. **128**: 229-234.
- Campos, C.E.M., Lima, J.C.D., Grandi, T.A., Machado, K.D., Pizani, P.S., and Hinrichs, R., *Solid State Ionic*, 2004. **168**: 205-210.
- Caruntu, G., Rarig, R., Dumitru, and O'Connor, C. J. *Journal of Materials Chemistry*, 2006. **16**(8): 752-758.

- Chan, K.S., Yunus, W.M.M., Yunus, W.M.Z.W., Talib, Z.A., and Kassim, A., *Physica B*, 2008. **403**: 2634-2638.
- Cutolo A., Daliento S., Sanseverino A., Vitale G.F. and Zeni L., *Solid State Electronics*, 1998. **42**(6): 1035 – 1038.
- Dhanam, M., Manoj, P.K., and Prabhu, R.R. *Journal of Crystal Growth*, 2005. **280** (3-4): 425-435.
- Fan, H., Zhang, M., Zhang, X., and Qian, Y., *Journal of Crystal Growth*, 2009. **311**: 4530-4534.
- Favier, J. P. Ph. D. Thesis. Photothermal experiments on condensed phase samples of agricultural interest: optical and thermal characterization. Wageningen Agricultural University, 1997.
- Flewitt, P.E.J., and Wild., R.K. *Physical methods for materials characterization* 2nd ed.; Institute of Physics: Bristol. 2001.
- Futamata, M., *Measurement Science and Technology*, 1992. **3**: 919-921.
- Ge, J.P., and Li, Y.D., *Journal of Materials Chemistry*, 2003. **13**: 911-915.
- Ghazanfar, U., Siddiqi, S.A., and Abbas, G., *Materials Science and Engineering: B*, 2005. **118**(1-3): 132-134.
- Ghobadi, N., and Badakhshan, T.A., *Optik - International Journal for Light and Electron Optics*, 2015.
- Girish, C.T., Maarit, K., and Ashok, K.R., *Journal of Solid State Chemistry*, 2013. **198**: 108-113
- Gonzalez, T.M.A., Cruz, O.A., Albor, A.M.L., and Castillo, A.F.L., *Thin Solid Films*, 2005. **480-481**: 358-361.
- Gronvold, F. *Acta Chemica Scandinavica*, 1970. **24**: 1036-1050.
- Gronvold, F., Kveseth, N.J., and Sveen, A., *Journal Chemistry Thermodynamics*, 1975. **7**: 617-632.
- Han, Z.H., Yu, S.H., Li, Y.P., Zhao, H.Q., Li, F.Q., Xie, Y., and Qian Y.T., *Chemistry of Materials*, 1999. **11**: 2302-2304.
- Hankare, P.P., Jadhav, B.V., Garadkar, K.M., Chate, P.A., Mulla, I.S., and Delekar, S.D., *Journal of Alloys and Compounds*, 2010. **490**: 228-231.
- Hayashi, T., Hashimoto, Y., Katsumoto, S., and Iyea, Y., *Applied Physics Letters*, 2001. **78**(12): 1691-1693.
- Henshaw, G., Parkin, I.V., and Shaw, G.A., *Journal of the Chemical Society, Dalton Transactions*, 1997. 231-236.

- Hummel, R.E. *Electronic Properties of Materials*; 3rd ed.; Springer-Verlag: New York. 2001.
- Iwasaki, T., Oda, S., Sawada, T. and Honda, K., *Journal of Chemical Physics*, 1980. **84**: 2800-2803.
- Jadhav, B.V., Hankare, P.P., and Delekar, S.D., *Journal of Materials Science: Materials in Electronics*, 2011. **22**:1433–1442.
- Johannes, D.B., and Volker, S., *Advance Material*, 2010. **22**: 4303-4307.
- Kale, R.B., and Lokhande, C.D., *Applied Surface Science*, 2004. **223**:343–351.
- Kannan, M.D., Balasundaraprabhu, R., Jayakumar, S., and Ramananthaswamy, P., *Solar Energy Materials and Solar Cells*, 2004. **81**(3): 379-395.
- Kassim, A, Ho, S. M., Tan, W.T., and Rosli, Y, *Ozean Journal of Applied Sciences*, 2011. **4**(4): 363-372.
- Kazmerski, L.L., Berry, W.B., and Allen, C.W., *Journal of Applied Physics*, 1972. **43**(8): 3515-3521.
- Kubelka, P., *Journal of the Optical Society of America*, 1948. **38**(5), 448-448.
- Kulifay, S.M., *Journal of Inorganic And Nuclear Chemistry*, 1963. **25**: 75-78.
- Liew, J.Y.C. Ph.D. Thesis. Structural, electrical, thermal and optical properties of polycrystalline chalcogenide compounds (CuSe, SnSe and Cu₂SnSe₃). Universiti Putra Malaysia, 2011.
- Liew, J.Y.C., Talib, Z.A., Yunus, W.M.M., Zainal, Z., Halim, S.A., Lim, K.P., Maksin, M.M., and Yusoff, W.D.W., *Jurnal Fizik Malaysia*, 2008. **29**: 3-4.
- Lima, C.A.S., Oliva, R., Cardenas, G.T., Silva, E.N., and Miranda, L.C.M., *Materials Letters*, 2001. **51**: 357-362.
- Lin, H., Huang, C.P., Li, W., Ni, C., Ismat, S., and Tseng, Y.H., *Applied Catalysis B: Environmental*, 2006. **68**:1–11.
- Liu, J.W., Lee, S.C., and Yang, C.H., *Materials Transactions*, 2008. **49**(7): 1694-1697.
- Liu, X., Zhang, N., Yi, R., Qiu, G., Yan, A., Wu, H., Meng, D., and Tang, M., *Material Science and Engineering B*, 2007. **140**: 38-43.
- Mandale, A.B., Badrinarayanan, S., Date, S.K., and Sinha, A.P.B., *Journal of Electron Spectroscopy and Related Phenomena*, 1984. **33**: 61-72.
- Mandelis, A. and Hess, P., *Progress in photothermal and photoacoustic Science and technology Volume IV: Semiconductor and electronic*

materials. Washington, USA: SPIE Press Publisher – The International Society for Optical Engineering. 2000.

Mandelis, A., and Hess, P., "Progress in photothermal and photoacoustic Science and technology", Mandelis, A. and Hess, P., eds., SPIE Optical Engineering Press, Bellingham, Washington, Vol. IV. 2000.

Mane, R.S., and Lokhande, C.D., *Materials Chemistry and Physics*, 2000. **65**: 1-31.

Marin, E., Riech, I., Diaz, P., and Vargas, H., *Analytical Science*, 2001. **17**:s288 – s290.

Masayuki Futamata, *Measurement Science and Technology*, 1992. **3**: 919-921.

Mendoza P.J., Mandelis A., Nicolaidis L., Huerta J., and Rodriguez M.E., *Analytical Sciences*, 2001. **17**: s269 – s272.

Mizuno, K., Yamamoto, S., Okamoto, H., Kuga, M., and Hashimoto, E., *Journal of Crystal Growth*, 2002. **237–239** (1) 367–372.

Moloto, N., Moloto, M.J., Coville, N.J., and Ray, S.S., *Journal of Crystal Growth*, 2011. **324**: 41-52.

Moloto, N., Moloto, M.J., Coville, N.J., and Ray, S.S., *Journal of Crystal Growth*, 2009. **311**: 3924-3932.

Neto, A.P., Vargas H., Leite N.F. and Miranda L.C.M., *Physical Review B*, 1989. **40** (6): 3924-3930.

NETZSCH, *Operating instructions LFA 457TM microflash*; NETZSCH-Geratebau GmbH: Gemany. 2006.

Niasari, M.S., and Sobhani, A., *Optical Materials*, 2013. **35**: 904–909.

Nibu, A.G., Aneeshkumar, B., Radhakrishnan, P., and Vallabhan, C.P.G., *Journal of Physics D: Applied Physics*, 1999. **32**: 1196-1200.

Nikolic, P.M., Todorovic, D.M., Vasiljevic, D.G., Mihajlovic, P., Radulovic, K., Ristovski, Z.D., Elazar, J., Blagojevic, V., and Dramicanin, M.D., *Microelectronics Journal*, 1996. **27**: 459.

Nordin, S. PhD Thesis. Photoelectrochemical properties of metal selenide thin films deposited by thermal vacuum evaporation in the presence of argon gas. Universiti Putra Malaysia, 2014.

Okada, T., and Ohno, S., *Journal of Non-Crystalline Solids*, 1999. **250-252**: 344-347.

Purohit, A., Chander, S., Nehra, S.P., and Dhaka, M.S., *Physica E*, 2015. **69**: 342-348.

- Rosencwaig, A. *Photoacoustic and photoacoustic spectroscopy*, John Wiley: New York. 1980.
- Rosencwaig, A. and Gersho, G. *Journal of Applied Physics*, 1976. **47**: 64-69.
- Salunkhe, R.R., Dhawale, D.S., Gujar, T.P., and Lokhande, C.D., *Materials Research Bulletin*, 2009. **44**(2):364-368.
- Seoudi, R., Shabaka, A.A., Elokri, M.M., and Sobhi, A. *Materials Letters*, 2007. **61**(16): 3451 – 3455.
- Sen, S.S., Biswas, N.N., and Khan, K.A., *Applied Energy*, 2000. **65**: 51-58.
- Shi, W., Zhang, X., and Che, G., *International Journal Of Hydrogen Energy*, 2013. **38**: 7037-7045.
- Sobhani, A., Davar, F., and Niasari, M.S., *Applied Surface Science*, 2011. **257**: 7982-7987.
- Sobhani, A., Niasari, M.S., and Davar, F., *Polyhedron*, 2012(a). **31**: 210-216.
- Sobhani, A., and Niasari, M.S., *Material Research Bulletin*, 2012(b). **47**: 1905-1911.
- Sobhani, A., and Niasari, M.S., *Superlattices and Microstructures*, 2014. **65**: 79-90.
- Soleimani, V., and Aghdaee, S.R., *Journal of Physics and Chemistry of Solids*, 2015. **81**:1-9.
- Sun, G.F., Wang, K., Zhou, R., Tong, Z.P., and Fang, X.Y., *Optics & Laser Technology*, 2015. **66**: 98-105.
- Uchida, H., Soga, T., Nishikawa, H., Jimbo, T., and Umeno, M., *Journal of Crystal Growth*, 1995. **150**: 681-684.
- Vigil, G.O., Ximello, Q.J.N., Aguilar, H.J., Gerardo, C.P., Cruz, O.A., Mendoza, A.J.G., Cardona, B.J.A., Ruiz, C.M., and Bermudez, V., *Semiconductor Science Technology*, 2006. **21**: 76-80.
- Vargas, W.E. *Journal of Optics A: Pure and Applied Optics*, 2002. **4**(4): 452.
- Wang, P., Somasundaram, P., Honig, J.M., and Pekarek, T.M., *Material Research Bulletin*, 1997. **32**(10): 1435-1440.
- Wang, X., Li, S.S., Kim, W.K., Yoon, S., Craciun, V., Howard, J.M., Easwaran, S., Manasreh, O., Crisalle, O.D., and Anderson, T.J., *Solar Energy Materials & Solar Cells*, 2006. **90**: 2855-2866.
- Xue, M.Z., and Fu, ZW., *Electrochemistry Communications*, 2006. **8**: 1855-1862.

- Yang, J., Cheng, G.H., Zeng, J.H., Yu, S.H., Liu, X.M., and Qian, Y.T., *Chemistry of Materials*, 2001. **13**:848-853.
- Yang, L., and Kruse, B. *Journal of the Optical Society of America*, 2004. **A21**, 1933-1941.
- Yap S.H., Master Thesis. Carrier transport and I-V characterization of Si, Au/Si and Ag/Si Silicides using photoacoustic and four point probe techniques. Universiti Putra Malaysia, 2005.
- Young, W.R., Jae, H.Y., Keon, S.K., Ki, W.K., Kun, W.S., and Dong, J.K., *Thermochimica Acta*, 2007. **255**: 86 – 89.
- Yuan, Z., Zhu, X., Wang, X., Cai, X., Zhang, B., Qiu, D., and Wu, H., *Thin Solid Films*, 2011. **519**: 3254-3258.
- Zainal Z, N. Saravanan N., and Mien, H. L., *Journal of Materials Science: Materials In Electronics*, 2005. **16**: 111– 117.
- Zhang, W., Hui, Z., Cheng, Y., Zhang, L., Xie, Y., and Qian, Y., *Journal of Crystal Growth*, 2000. **209**: 213-216.
- Zhuang, Z., Peng, Q., Zhuang, J., Wang, X., and Li, Y., *Chemistry - A European Journal*, 2006. **12**: 211 – 217.